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## (54) COMPOSITION FOR INTEGUMENT CONTAINING PLANT EXTRACT

## (57)Abstract:

PROBLEM TO BE SOLVED: To obtain a composition for integument having no adverse effect on the skin and the mucosa and excellent antimicrobial activity.

SOLUTION: This composition for integument comprises hyaluronic acid besides a plant component having antimicrobial activity and has no adverse effect on the skin and the mucosa and excellent antimicrobial activity.

## LEGAL STATUS

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